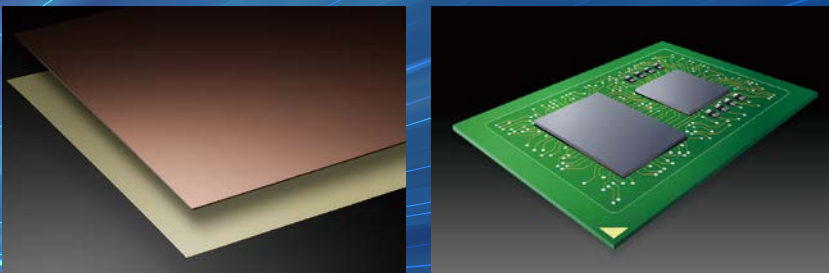


Electronic Materials



**Dk 3.08 Df 0.0012
@14GHz**

Tg (DMA) 220°C

**T288 (with copper)
>120min**

**Applications
Network / Wireless**

Routers, Switches, Optical Transmission Equipment, Servers, AI Servers, Base Stations, Semiconductor Test Equipment, Probe Cards.

MEGTRON8S

Laminate
R-579YS(U)/(N)
Prepreg
R-569YS(U)/(N)

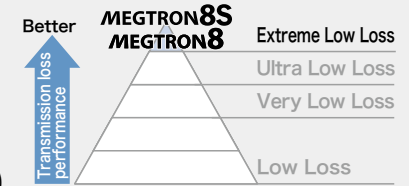
(U): Ultra-low Df glass cloth type
(N): Low Dk glass cloth type

MEGTRON8

Laminate
R-579Y(U)/(N)
Prepreg
R-569Y(U)/(N)

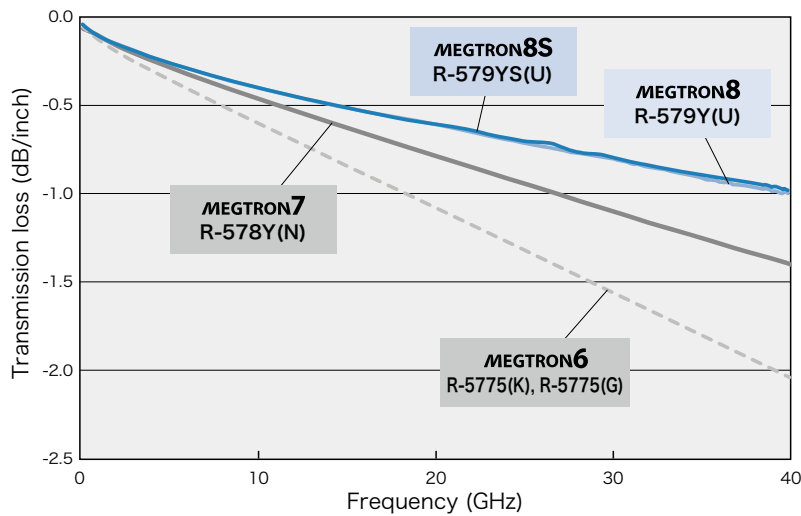
Ultra-low transmission loss, highly heat-resistant multi-layer circuit board materials

The new materials support 800GbE used for next-generation high-speed communication technology. Comparison of MEGTRON8 R-579Y(U) and MEGTRON7 R-578Y(N), improving transmission loss by about 30% (@28GHz).



Frequency dependence by transmission loss

About 30% improvement in transmission loss compared to MEGTRON8 R-579Y(U), MEGTRON7 R-578Y(N)*



* Improvement at 28GHz

$$\frac{\Delta \text{Transmission loss (MEGTRON7-MEGTRON8)}}{\text{Transmission loss (MEGTRON7)}} \times 100 \approx 30(\%)$$

Evaluation sample (cross section)



PCB construction	3L PCB Strip line
Copper thickness	18 μm (IL)
Core	0.13mm
Prepreg	0.15mm
Z ₀ Impedance	50Ω
Inner treatment	No-surface treatment
Measurement method	2 port S-parameter
Frequency range	0.2 - 40GHz
De-embedded	Multiline TRL method

The above data are typical values and not guaranteed values.

General properties

Item	Test method	Condition	Unit	MEGTRON8S	MEGTRON8S	MEGTRON8	MEGTRON8	
				R-579YS(U) Ultra-low Df glass cloth	R-579YS(N) Low Dk glass cloth	R-579Y(U) Ultra-low Df glass cloth	R-579Y(N) Low Dk glass cloth	
Tg	DMA	A	°C	220	220	220	220	
CTE z-axis	α1	IPC-TM-650 2.4.24	A	ppm/°C	35	35	50	50
					α2	240	240	270
T288(with copper)	IPC-TM-650 2.4.24.1	A	min	>120	>120	>120	>120	
Dk	Balanced-type circular disk resonator method	C-24/23/50	-	3.19	3.22	3.08	3.13	
Df				0.0012	0.0015	0.0012	0.0016	
Peel strength	1oz(35μm)	IPC-TM-650 2.4.8	A	kN/m	0.7 [H-VLP3]	0.7 [H-VLP3]	0.7 [H-VLP3]	0.7 [H-VLP3]

The sample thickness is 0.75mm.

Please see our website for Notes before you use.

The above data are typical values and not guaranteed values.

**DK 3.31 Df 0.0023
@14GHz**

T_g (DSC) 200°C

**T288 (with copper)
>120min**

Applications
Network / Wireless

ICT Infrastructure Equipment, Supercomputer,
Measuring Instrument, Antenna (Base Station,
Automotive Millimeter-Wave Radar)

MEGTRON7

Laminate

R-578Y(N)* R-578Y(GN)* R-578Y(GE)

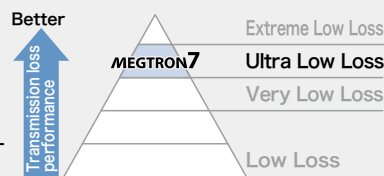
Prepreg

R-568Y(N)* R-568Y(GN)* R-568Y(GE)

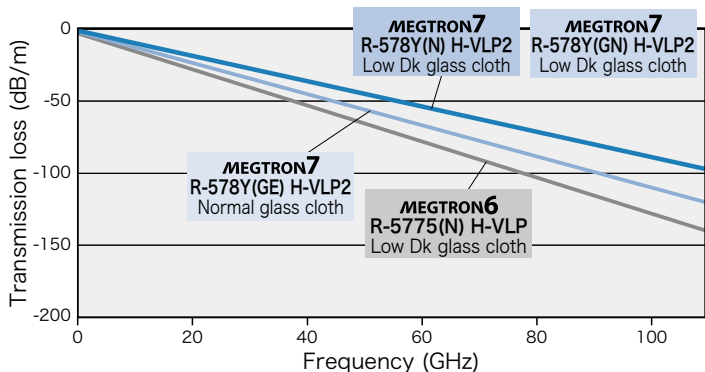
*Low Dk glass cloth type

Ultra-low transmission loss, highly heat-resistant multi-layer circuit board materials

Due to our industry leading low dielectric constant and dissipation factor, these materials are suitable for high-speed data transmission by servers and routers using high-layer-count, large-size PCB designs.



Frequency dependence by transmission loss



Heat resistance of high multi-layered

Result

Drill diameter	φ0.3mm		
Wall to wall distance	0.4mm	0.5mm	0.6mm
R-578Y(N) Low Dk glass cloth/H-VLP2	pass	pass	pass
R-578Y(GN) Low Dk glass cloth/H-VLP2	pass	pass	pass

Condition

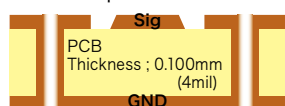
260°C reflow x 20times

Construction

32 Layers
Board thickness: 4.5mm

Construction

Microstrip line



Measurement	2 port S-Parameter
Frequency	10MHz-110GHz
De-embedded	TRL method
Measurement line	adjust to 50Ω(Z ₀)

Layer1: Signal line (line width: 270μm, Cu thickness: 24μm)

Layer2: GND plane (Cu thickness: 24μm)



R-578Y(N)



R-578Y(GN)

General properties

Item	Test method	Condition	Unit	MEGTRON7 R-578Y(N)	MEGTRON7 R-578Y(GN)	MEGTRON7 R-578Y(GE)	
				Low Dk glass cloth	Low Dk glass cloth	Normal glass cloth	
T _g	DSC	A	°C	200	200	200	
CTE z-axis	α1	IPC-TM-650 2.4.24	A	ppm/°C	42	42	
					α2	280	280
T288(with copper)	IPC-TM-650 2.4.24.1	A	min	>120	>120	>120	
Dk	13, 14GHz	Balanced-type circular disk resonator method	C-24/23/50	-	3.31 [14GHz]	3.31 [14GHz]	3.60 [13GHz]
Df					0.0023 [14GHz]	0.0023 [14GHz]	0.0034 [13GHz]
Peel strength*	1oz(35μm)	IPC-TM-650 2.4.8	A	kN/m	0.8	0.8	0.8

The sample thickness is 0.75mm.

* R-578Y(GN), R-578Y(GE): H-VLP2, R-578Y(N): H-VLP Copper

Please see our website for Notes before you use.

The above data are typical values and not guaranteed values.

**Dk 3.36 Df 0.0029
@13GHz**

Tg (DMA) 250°C

**T320 (with copper)
>120min**



Halogen-free **MEGTRON6**

Laminate

R-537Y(N)* R-537Y(E)

Prepreg

R-527Y(N)* R-527Y(E)

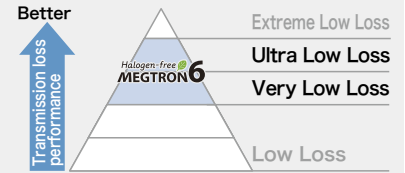
*Low Dk glass cloth type

Halogen-free ultra-low transmission loss multi-layer circuit board materials

The industry standard high-speed, ultra-low loss material.

Transmission loss is between MEGTRON6 R-5775(K)/R-5775(G) and MEGTRON7 R-578Y(N).

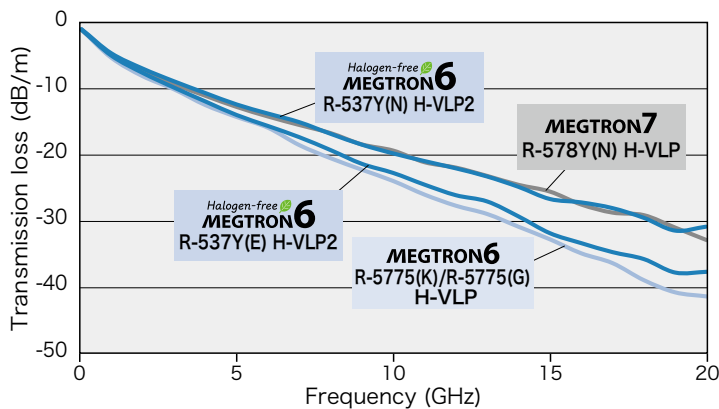
Excellent HDI and thermal performance.



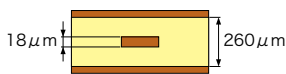
Applications
Network / Wireless

ICT Infrastructure Equipment, High Speed Networking (High-End Server/Router, Optical Network, Switch), High-Layer-Count PCB

Frequency dependence by transmission loss



Construction



Line length	200mm , 100mm
Line width	125µm
Impedance	50Ω
Inner Cu treatment	No-surface treatment
Core	0.13mm
Prepreg	#2116 56% x 1ply

Heat resistance of high multi-layered

Result

Drill diameter	φ0.3mm	
Wall to wall distance	0.3mm	0.5mm
Halogen-free MEGTRON6 R-537Y(E)	pass	pass

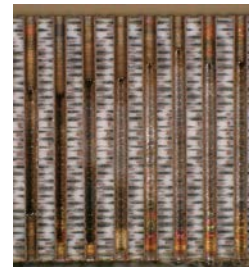
Condition

260°C reflow x 10times

Construction

32 Layers

Board thickness: 4.5mm



General properties

Item	Test method	Condition	Unit	Halogen-free MEGTRON6 R-537Y(N) Low Dk glass cloth	Halogen-free MEGTRON6 R-537Y(E) E glass cloth	MEGTRON6 R-5775(K)/R-5775(G) E glass cloth	
Tg	DMA (1Hz)	A	°C	250	250	210*1	
CTE z-axis	α1/α2	IPC TM-650 2.4.24	ppm/°C	39/200	39/200	45/260	
T288(with copper)	IPC-TM-650 2.4.24.1	A	min	>120	>120	>120	
T320(with copper)				>120	>120	50	
Dk	13GHz	Balanced-type circular disk resonator method	C-24/23/50	-	3.36	3.66	3.62
Df					0.0029	0.0037	0.0046
Peel strength	1oz(35µm)	IPC-TM-650 2.4.8	A	kN/m	0.6*2	0.6*2	0.8*3

The sample thickness is 0.75mm.

*1 10Hz *2 H-VLP2 Copper *3 H-VLP Copper

Please see our website for Notes before you use.

industrial.panasonic.com/tw/electronic-materials

Our Halogen-free materials are based on JPCA-ES-01-2003 standard and others.

The above data are typical values and not guaranteed values.

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**DK 3.34 Df 0.0037
@13GHz**

Tg (DSC) 185°C

**T288 (with copper)
>120min**

Applications
Network / Wireless

ICT Infrastructure Equipment, Supercomputer,
Measuring Instrument, Antenna (Base Station,
Automotive Millimeter-Wave Radar)

MEGTRON6

Laminate

R-5775(N)* R-5775(K) R-5775(G)

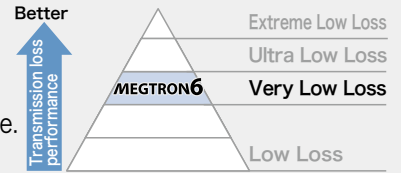
Prepreg

R-5670(N)* R-5670(K) R-5670(G)

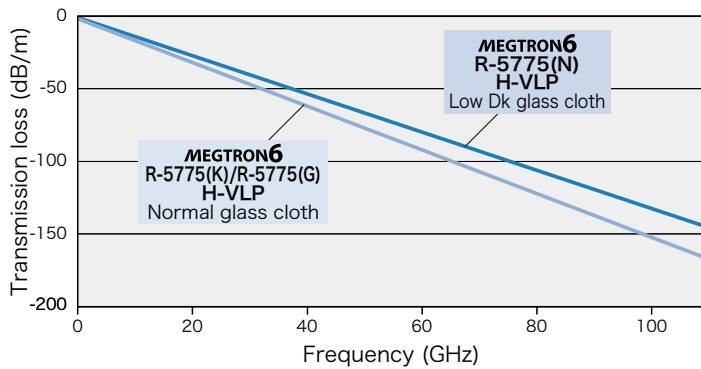
*Low Dk glass cloth type

Ultra-low transmission loss, highly heat-resistant multi-layer circuit board materials

The industry standard for high speed, ultra-low loss PCB material. Excellent HDI and thermal performance.



Frequency dependence by transmission loss



Heat resistance of high multi-layered

Result

Drill diameter	φ0.3mm	
Wall to wall distance	0.5mm	0.6mm
MEGTRON6 (Low Dk glass cloth)	pass	pass

Condition

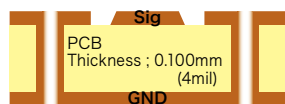
260°C reflow x 10times

Construction

32 Layers
Board thickness: 4.5mm

Construction

Microstrip line



Measurement	2 port S-Parameter
Frequency	10MHz-110GHz
De-embedded	TRL method
Measurement line	adjust to 50Ω(Zo)

Layer1: Signal line (line width: 270μm, Cu thickness: 24μm)

Layer2: GND plane (Cu thickness: 24μm)



General properties

Item	Test method	Condition	Unit	MEGTRON6 R-5775(N) Low Dk glass cloth	MEGTRON6 R-5775(K)/R-5775(G) Normal glass cloth
Tg	DSC	A	°C	185	185
CTE z-axis	IPC-TM-650 2.4.24	A	ppm/°C	45	45
				260	260
T288(with copper)	IPC-TM-650 2.4.24.1	A	min	>120	>120
Dk	Balanced-type circular disk resonator method	C-24/23/50	-	3.34	3.62
Df				0.0037	0.0046
Peel strength*	1oz(35μm)	IPC-TM-650 2.4.8	A	kN/m	0.8

The sample thickness is 0.75mm.

* H-VLP Copper

Please see our website for Notes before you use.

The above data are typical values and not guaranteed values.



Circuit board materials for IC substrate

LEXCMGX Series

Enables thinner and smaller IC substrates with lower warpage.

Line-up

Package Application	FC-xGA	Module	CSP	FC-CSP
	<ul style="list-style-type: none"> • CPU for Sever/Desktop/Laptop • GPU for AI/ADAS/Gaming • FPGA 	<ul style="list-style-type: none"> • AiP • PAM • FEM 	<ul style="list-style-type: none"> • DRAM • NAND/PMIC • Mini LED 	<ul style="list-style-type: none"> • APU • RF-IC

LEXCMGX

Product	Ultra Low CTE / High Reliability	Low Dk / Low Df	Low CTE / Ultra Thin Material
	R-1515V / R-1515K • Low warpage • Stress release R-G635 New • Low warpage • Stress release • Processability	R-G740M Under development • Low Dk RCC • Thinner R-G645 Under development • Excellent Low Dk/Df • Thinner	R-G515S / R-G515E • Low warpage • Fine laminate-ability • Ultra thin prepreg line-up R-151YE • Low warpage • High modulus R-1515H • High Tg
	Low CTE / High Heat Resistance		
	R-1515W • Low warpage • High modulus		

General properties

Item	Glass transition temp.(Tg)	CTE x,y-axis	Dielectric constant(Dk)*1	Dissipation factor(Df)*1	Flexural modulus*1	
		α 1				
Test method	DMA*2	TMA	IPC-TM-650 2.5.5.9		JIS C 6481	
Condition	A	A	C-24/23/50		25°C	250°C
Unit	°C	ppm /°C	-		GPa	
R-1515V	260	3-5	4.4	0.016	30	14
R-1515K	260	7	4.6	0.015	27	12
R-151YE	270	9	4.7	0.011	33	18
R-G515S	220-240	4-6	4.2	0.008	28	-
R-G515E	220-240	6-8	4.4	0.008	24	-
R-1515W	250	9	4.8	0.015	35	21
R-G740M	240 (60μm: DMA Tensile)	40-60 (60μm: TMA Tensile)	2.6*3 (60μm: 10GHz)	0.003*3 (60μm: 10GHz)	1.0-2.0 (60um: DMA Tensile)	
R-G645(L)	230-250	10	3.5*3 (10GHz)	0.0026*3 (10GHz)	25	-
R-G645(E)	230-250	10	4.0*3 (10GHz)	0.0045*3 (10GHz)	29	-
R-1515H	270	12	4.8	0.015	27	-

The sample thickness is 0.1 mm.

*1 0.8mm *2 Measurement in tensile mode. R-1515W: Measurement in bending mode.

*3 Cavity resonator method

Please see our website for Notes before you use.

Our Halogen-free materials are based on JPCA-ES-01-2003 standard and others.

The above data are typical values and not guaranteed values.

CTE x,y-axis 3-5ppm/°C
(Low CTE glass cloth)

Stress relaxation

Good thickness variation

Applications
IC Package
FC-BGA (CPU, GPU, FPGA, ASIC)



LEXCMGX

Laminate **R-1515V*** Laminate **R-1515K**

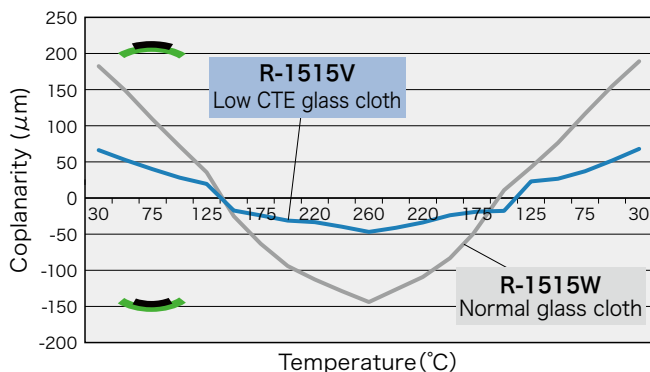
*Low CTE glass cloth type

Low CTE IC substrate materials designed to improve reliability

Low CTE reduces warping and addresses a critical challenge with the IC packaging process. Flexibility and buffering features improve the reliability of the assembly process. Offers excellent thickness tolerances.

IC package warpage

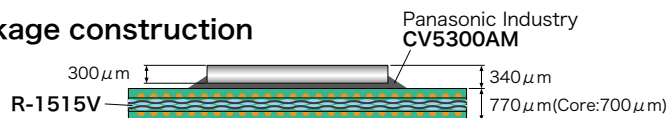
Result



Sample

Core thickness	700 μm t (12-12 μm)
Package size	35 x 35mm (Die size 15 x 15mm)

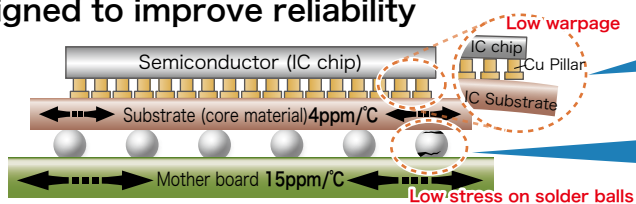
Package construction



A wide range of thickness options

R-1515V (Low CTE glass cloth)	0.21~1.8mm
R-1515K (Normal glass cloth)	

Designed to improve reliability



Low CTE

Low thermal expansion coefficient (CTE): close to that of silicon IC chips, which reduces warping and addresses a critical challenge with the IC chip packaging process.

Stress relaxation

Combines flexibility and buffering features while retaining low thermal expansion properties through a stress relaxation technology, improving the reliability of the assembly process.

General properties

Item	Test method	Condition	Unit	LEXCMGX R-1515V	LEXCMGX R-1515K	Conventional Normal glass cloth	
				Low CTE glass cloth	Normal glass cloth		
Glass transition temp.(Tg)	DMA*2	A	°C	260	260	260	
CTE x-axis	TMA*2	A	ppm/°C	3-5	7	8-10	
CTE y-axis				3-5	7	8-10	
Dielectric constant(Dk)*1	1GHz	IPC-TM-650 2.5.5.9	C-24/23/50	-	4.4	4.6	4.8
Dissipation factor(Df)*1				0.016	0.015	0.015	
Elastic modulus*1	IPC-TM-650 2.4.4*3	25°C	GPa	30	27	33	
				250°C	14	12	21

The sample thickness is 100 μm. *1 700 μm *2 Measurement in tensile mode. *3 The IPC standard determines the test sample size, methods and conditions, etc. but there is no formula for calculating the elastic modulus. Therefore, we quantified it according to JIS C 6481.

Our Halogen-free materials are based on JPCA-ES-01-2003 standard and others.

The above data are typical values and not guaranteed values.



LEXCMGX

Laminate

Prepreg

R-151YE R-141YE

High elasticity Low CTE Ultra-thin IC substrate materials

Contribute to thin IC package by ultra-thin material and decrease the substrate warpage by low CTE property.

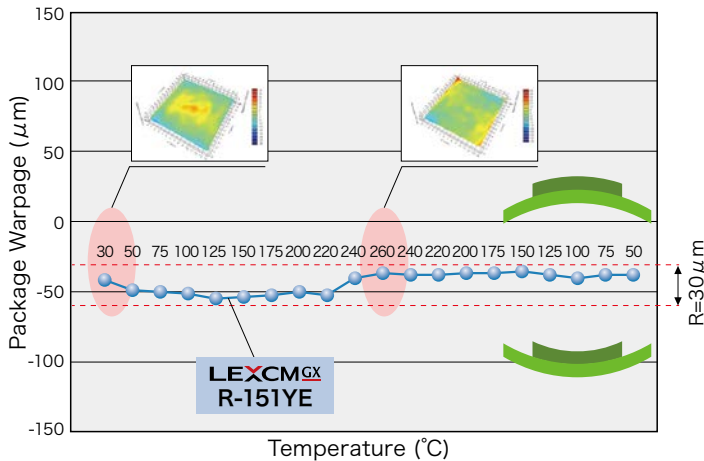
Flexural modulus
25°C 33GPa

CTE x, y-axis
9ppm/°C

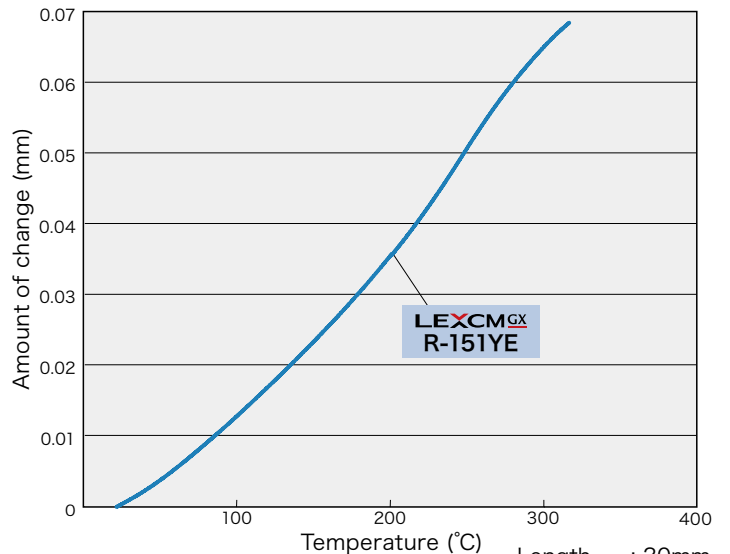
Tg(DMA) 270°C

Applications
IC Package
CSP (DRAM, NAND/ PMIC, Mini LED, etc.),
FC-CSP (APU, RF-IC, etc.)

Package warpage (FBGA)



Thermal expansion (x-axis)



Length : 20mm
Thickness : 0.1mm
Method : TMA

Construction

FBGA	14x14mm
Chip size	10x10x0.15mm
Substrate thickness	0.10mm (Core 0.04mm)

General properties

Item	Test method	Condition	Unit	LEXCMGX R-151YE
Glass transition temp.(Tg)	DMA*2	A	°C	270
Thermal decomposition temp.(Td)	TGA	A	°C	390
CTE x-axis	Internal method	A	ppm/°C	9
CTE y-axis				9
CTE z-axis	IPC-TM-650 2.4.24	A		22*1
				95*1
Flexural modulus	JIS C 6481	25°C	GPa	33*1
		250°C		18*1

The sample thickness is 0.1mm.
*1 0.8mm *2 measurement in tensile mode

Please see our website for Notes before you use.

Our Halogen-free materials are based on JPCA-ES-01-2003 standard and others.

The above data are typical values and not guaranteed values.

Flexural modulus
25°C 35GPa

CTE x, y-axis
9ppm/°C

Tg(DMA) 250°C

Applications
IC Package
IC substrate



LEXCMGX

Laminate

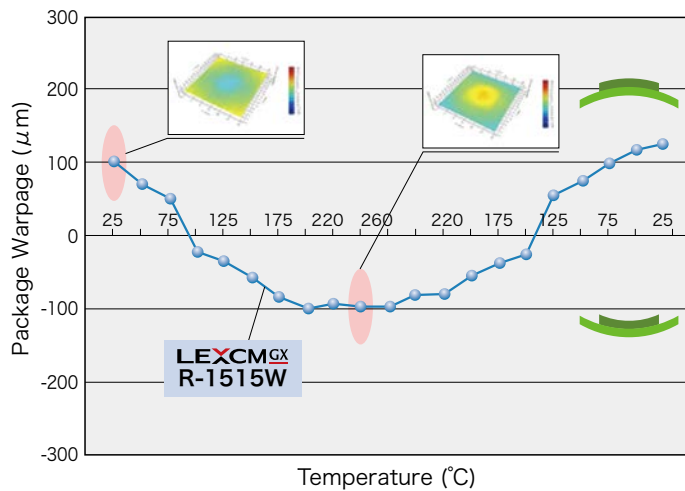
Prepreg

R-1515W R-1410W

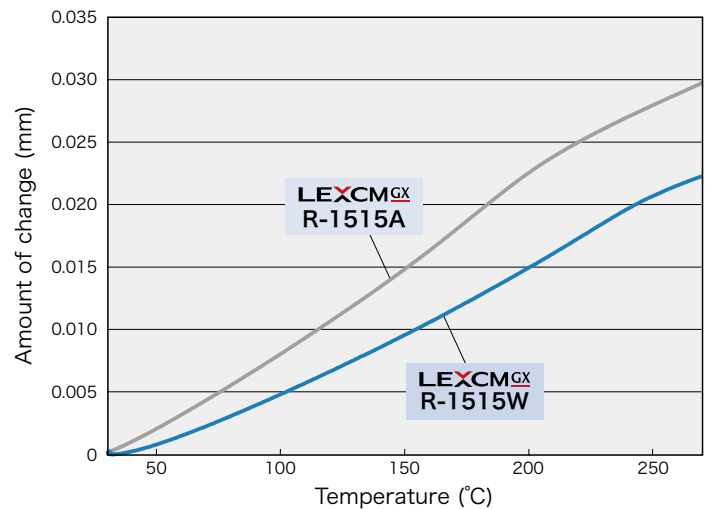
High elasticity Low CTE IC substrate materials

Achieve more functionality (multi-pin and integrated circuit) the large-sized Package by excellent modulus and highly heat resistant property.

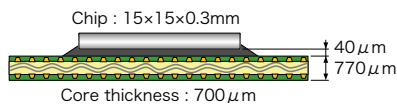
IC package warpage



Thermal expansion (x-axis)



Construction



Length : 10mm
Thickness : 0.8mm (8ply)
Method : TMA

General properties

Item	Test method	Condition	Unit	LEXCMGX R-1515W
Glass transition temp.(Tg)	DMA*2	A	°C	250
Thermal decomposition temp.(Td)	TGA	A	°C	390
CTE x-axis	Internal method	A	ppm/°C	9
CTE y-axis				9
CTE z-axis	IPC-TM-650 2.4.24	A		22
				97
Flexural modulus*1	JIS C 6481	25°C	GPa	35
		250°C		21

The sample thickness is 0.1 mm.
*1 0.8mm *2 Measurement in bending mode
Please see our website for Notes before you use.

Our Halogen-free materials are based on JPCA-ES-01-2003 standard and others.
The above data are typical values and not guaranteed values.

CTE x,y-axis 4-6ppm/°C
(Low CTE glass cloth)

Low warpage

Ultra-thin
excellent moldability

Applications
IC Package

CSP (PoP-Bottom, Flip-Chip, Memory, Module, etc.)



LEXCMGX

Laminate

R-G515S* **R-G515E**

Prepreg

R-G510S* **R-G510E**

*Low CTE glass cloth type

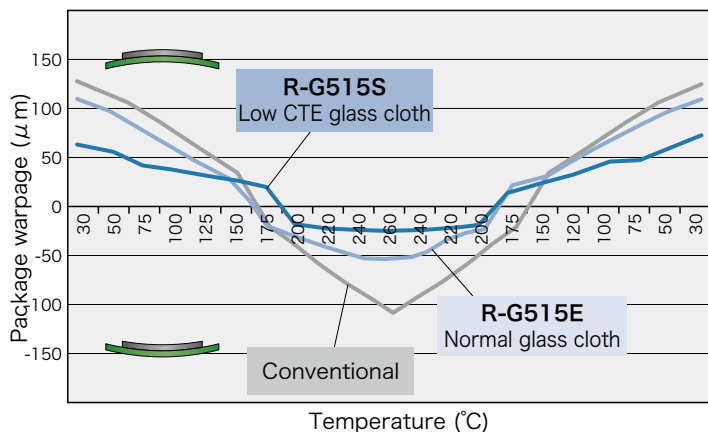
Low CTE ultra-thin IC substrate materials

With an insulation layer thickness of 15μm or less, these low-profile materials enable thinner IC package designs. The low CTE reduces warpage and increases reliability.

IC package warpage

R-G515S, with low CTE glass cloth, reduces warpage to about half that of conventional Panasonic materials.

Result



Package construction

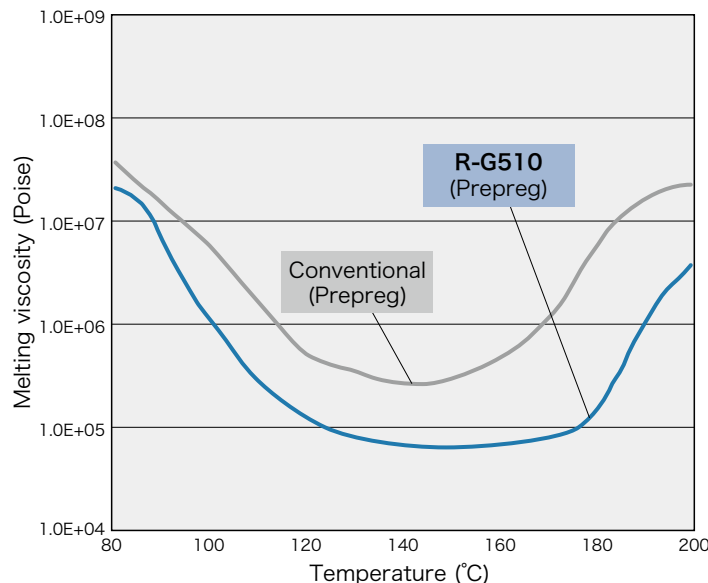


Package size	12.5 x 12.5mm
Die size	10 x 10 x 0.10mmt
CUF material	Panasonic CV5300AM
Substrate thickness	0.2mmt (2L Cu:12μm)

Melting and curling behavior

R-G510 has a wider melting area and higher moldability than conventional Panasonic materials.

Result



General properties

Item	Test method	Condition	Unit	LEXCMGX R-G515S Low CTE glass cloth	LEXCMGX R-G515E Normal glass cloth
Glass transition temp.(Tg)	DMA*2	A	°C	220-240	220-240
CTE x-axis	α 1 Internal method	A	ppm/°C	4-6	6-8
CTE y-axis				4-6	6-8
Dielectric onstant(Dk)*1	1GHz IPC-TM-650 2.5.5.9	C-24/23/50	-	4.2	4.4
Dissipation factor(Df)*1				0.008	0.008
Flexural modulus*1	JIS C 6481	25°C	GPa	28	24

The sample thickness is 0.1mm.
*1 0.8mm *2 Measurement in tensile mode

Please see our website for Notes before you use.

Our Global Business

Panasonic Industry Co., Ltd. Electronic Materials Business Division



Osaka(Headquarters)

- Sales & Marketing Business Unit
- Planning Center
- Technology Development Center
- SCM Center
- Advanced Materials SBU
- Manufacturing and Quality Innovation Center

Tokyo Nagoya

- Sales & Marketing Business Unit

Sales/Marketing R&D

Koriyama Plant



Manufacturing LAB R&D

- Multi-layer materials

Koriyama Plant (West Factory)



Manufacturing

- Multi-layer materials

Yokkaichi Plant



Manufacturing R&D

- Molding compounds

Yokkaichi Plant (South Factory)



Manufacturing LAB R&D

- Glass composite materials
- Flexible materials
- Encapsulation materials
- Advanced films

Panasonic Industrial Devices Materials Europe GmbH



Manufacturing <Austria>

Sales/Marketing

- Electronic Materials European R&M Group
- Multi-layer materials

Panasonic Industrial Devices Sales Company of America



Sales/Marketing

Electronic Materials Division US R&M Group

Panasonic Industrial Devices Materials (Guangzhou) Co., Ltd.



Manufacturing R&D

Sales/Marketing

- Electronic Materials China R&D Center
- Electronic Materials China R&M Group
- Multi-layer materials

Panasonic Industrial Devices Materials (Suzhou) Co., Ltd.



Manufacturing

- Multi-layer materials
- Glass composite materials

Panasonic Industrial Devices Materials (Shanghai) Co., Ltd.



Manufacturing

- Molding compounds
- Encapsulation materials

Panasonic Industrial Devices Materials Taiwan Co., Ltd.



Manufacturing R&D

Sales/Marketing

- Taiwan Semiconductor Materials R&D Center
- Multi-layer materials

Panasonic Manufacturing Ayuthaya Co., Ltd.



Manufacturing <Thailand>

Sales/Marketing

- Paper phenolic materials
- Molding compounds
- Encapsulation materials

Electronic Materials South Asia R&D Center

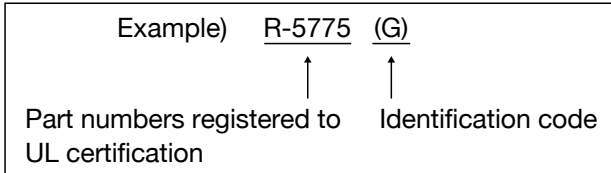


R&D <Singapore>

- Encapsulation materials

Notes before you use

- User must verify the suitability and fitness for intended application by quality testing, evaluation or other means at your own option before any adoption, use or change of use conditions of a product listed in this catalog.
- We would like to have a delivery specifications mutually agreed for the product that you have decided to use. The agreements defined in the delivery specifications are assigned higher priority.
- Please note that images shown may differ from the actual product in color.
- Please note that specifications and external design are subject to change without notice.
- For details on products in this catalog, please contact your distributor or our sales department.
- Any letters with parentheses () at the end of a part number are for identification code in our company and are not included in the part numbers registered for UL certification.



Safety Information

- Before using the product, please read the delivery specifications carefully or contact the distributor from which you purchased the product or our sales department.
- The products in this catalog are Electronic circuit board materials for electronic and electrical devices. Do not use them for other than specified use.

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